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DATE MAILED: 04/06/2006

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/808,793	03/24/2004	Ervin T. Hill	42P18020	6018
7:	590 04/06/2006		EXAMINER	
Michael A. Bernadicou			YEVSIKOV, VICTOR V	
BLAKELY, SC)KOLOFF, TAYLOR & Z	AFMAN LLP	· · · · · · · · · · · · · · · · · · ·	· · · · · · · · · · · · · · · · · · ·
Seventh Floor		•	ART UNIT	PAPER NUMBER
12400 Wilshire	Boulevard		2891	
Los Angeles, C	CA 90025		DATE MAN ED 04/06/000	

Please find below and/or attached an Office communication concerning this application or proceeding.

			\mathcal{H}			
	Application No.	Applicant(s)				
	10/808,793	HILL ET AL.				
Office Action Summary	Examiner	Art Unit				
	Victor V. Yevsikov	2891				
The MAILING DATE of this communication Period for Reply	appears on the cover sheet w	th the correspondence address				
A SHORTENED STATUTORY PERIOD FOR REWHICHEVER IS LONGER, FROM THE MAILING - Extensions of time may be available under the provisions of 37 CF after SIX (6) MONTHS from the mailing date of this communication - If NO period for reply is specified above, the maximum statutory pe - Failure to reply within the set or extended period for reply will, by st Any reply received by the Office later than three months after the mearned patent term adjustment. See 37 CFR 1.704(b).	G DATE OF THIS COMMUNIO R 1.136(a). In no event, however, may a r riod will apply and will expire SIX (6) MON atute, cause the application to become AB	CATION. eply be timely filed THS from the mailing date of this communication ANDONED (35 U.S.C. § 133).				
Status						
1) Responsive to communication(s) filed on 1	7 February 2006.					
2a) This action is FINAL . 2b) ⊠ ²	☐ This action is FINAL . 2b) ☐ This action is non-final.					
3) Since this application is in condition for allo	wance except for formal matt	ers, prosecution as to the merits is	S			
closed in accordance with the practice und	er <i>Ex parte Quayle</i> , 1935 C.D	. 11, 453 O.G. 213.				
Disposition of Claims						
4)⊠ Claim(s) <u>1-19</u> is/are pending in the applicat	tion.					
4a) Of the above claim(s) is/are with		_				
5) Claim(s) is/are allowed.						
6)⊠ Claim(s) <u>1-19</u> is/are rejected.						
7) Claim(s) is/are objected to.						
8) Claim(s) are subject to restriction ar	nd/or election requirement.					
Application Papers						
9) The specification is objected to by the Exan	niner.					
10)⊠ The drawing(s) filed on 24 March 2004 is/ar	re: a)⊠ accepted or b)□ obj	ected to by the Examiner.				
Applicant may not request that any objection to	the drawing(s) be held in abeyar	ice. See 37 CFR 1.85(a).				
Replacement drawing sheet(s) including the con	rrection is required if the drawing	(s) is objected to. See 37 CFR 1.121(d).			
11)☐ The oath or declaration is objected to by the	Examiner. Note the attached	Office Action or form PTO-152.				
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for fore	eign priority under 35 U.S.C. §	119(a)-(d) or (f).				
1. Certified copies of the priority docum	ents have been received.					
2. Certified copies of the priority docum	ents have been received in A	pplication No				
3. Copies of the certified copies of the	oriority documents have been	received in this National Stage				
application from the International Bu	reau (PCT Rule 17.2(a)).					
* See the attached detailed Office action for a	list of the certified copies not	received.				
Attachment(s)						
1) Notice of References Cited (PTO-892)		Summary (PTO-413)				
 Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449 or PTO/SB 	·	s)/Mail Date nformal Patent Application (PTO-152)				
Paper No(s)/Mail Date <u>3/24/4</u> .	6) Other:					

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DETAILED ACTION

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.
- 2. Claims 1, 8,9, and 10, 18 and 19 are rejected under 35 U.S.C. 102(e) as being anticipated by Chowdhury (US 2004/0110387 A1).

With respect to claims 1 and 10 Chowdhury teaches a method comprising:

forming a thin film stack (or flash memory gate stack) on a substrate 10, wherein the thin film stack includes at least a polysilicon layer 105 and an oxide layer 102;

forming a hardmask layer 135 on the thin film stack 125;

forming an anti-reflective coating (ARC) layer 145 on the hardmask layer 135; wherein the ARC layer comprises a different material (SiN₂, SiON, (§ 0034)) than the hardmask layer (WN, TaN,NbN, TiN, (§ 0022));

patterning the ARC layer;

etching the hardmask layer using the patterned ARC layer as a mask; and etching the thin film stack using the hardmask layer as a mask; and wherein:.

Reference: figs. 2 - 9 with corresponding text.

With respect to claims 8, 9,18 and 19 Chowdhury teaches a method wherein

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the ARC layer is removed during the etching of the thin film stack; removing the hardmask material from the thin film stack (figs 8 and 9 with corresponding text).

Claim Rejections - 35 USC § 103

- 3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 4. The factual inquiries set forth in *Graham* v. *John Deere Co.*, 383 U.S. 1, 148 USPQ 459 (1966), that are applied for establishing a background for determining obviousness under 35 U.S.C. 103(a) are summarized as follows:
 - 1. Determining the scope and contents of the prior art.
 - 2. Ascertaining the differences between the prior art and the claims at issue.
 - 3. Resolving the level of ordinary skill in the pertinent art.
 - 4. Considering objective evidence present in the application indicating obviousness or nonobviousness.
- 5. This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

6. Claims 2 –5 and 11,12, 14 and 15 are rejected under 35 U.S.C. 103(a) as being unpatentable over Chowdhury (US 2004/0110387 A1).

These claims are rejected as being prima facie obvious without showing that the claimed ranges (concentration, temperature, process time) achieve unexpected results relative to the prior art range.

In re Woodruff, 16 USPQ2d 1935, 1937 (Fed. Cir. 1990). See also In re Huang, 40 USPQ2d 1685, 1688 (Fed. Cir. 1996) (claimed ranges of a result effective variable, which do not overlap the prior art ranges, are unpatentable unless they produce a new and unexpected result which is different in kind and not merely in degree from the results of the prior art). See also In re Boesch, 205 USPQ 215 (CCPA 1980) (discovery of optimum value of result effective variable in known process is ordinarily within skill of art) and In re Aller, 105 USPQ 233 (CCPA 1955) (selection of optimum ranges within prior art general conditions is obvious).

7. Claims 6 and 16 are rejected under 35 U.S.C. 103(a) as being unpatentable over Chowdhury In view of Mui et al. (US 2005/0085090 A1).

With respect to claims 6 and 16 Chowdhury teaches the features detailed previously but lack a discussion on method wherein the hardmask layer comprises amorphous carbon.

However, Mui teach the method wherein the hardmask layer comprises amorphous carbon (§ 0025).

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Therefore, it would have been obvious to one of ordinary skill in the art to use method of forming hardmask layer as taught by Chowdhury / Mui as is useful in the optimizing on the field of semiconductor processing.

8. Claim 13 is rejected under 35 U.S.C. 103(a) as being unpatentable over Chowdhury In view of Wang et al. (US 6,509,237 B2).

With respect to claim 13 Chowdhury teaches the features detailed previously but lack a discussion on method wherein the flash memory gate stack is comprised of a gate dielectric layer, a floating gate layer, an inter-electrode dielectric layer, and a control gate electrode layer.

However, Wang ('237) teach the method wherein gate stack 14 is a flash memory gate stack is shown comprising a control gate 16 and a floating gate 18, with insulating layers 19 separating control gate 16 from floating gate 18 and floating gate 18 from substrate 12 (col.2, lines 43-56, fig.1a).

Therefore, it would have been obvious to one of ordinary skill in the art to use method of forming flash memory gate stack as taught by Chowdhury / Wang as is useful in the optimizing on the field of semiconductor processing.

9. Claims 7 and 17 are rejected under 35 U.S.C. 103(a) as being unpatentable over Chowdhury in view of Ying et al. (US 2004/0209476 A1).

With respect to claims 7 and 17 Chowdhury teaches the features detailed previously but lack a discussion on method wherein the hardmask layer comprises Applied Materials@ Advanced Patterning FilmTM.

However, Ying teach the method wherein the hardmask layer comprises Applied Materials@ Advanced Patterning FilmTM (§0027).

Therefore, it would have been obvious to one of ordinary skill in the art to use method of forming hardmask as taught by Chowdhury / Ying as is useful in the optimizing on the field of semiconductor processing.

Conclusion

10. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Victor Yevsikov whose telephone number is (571) 272-1910. The examiner can normally be reached on Monday –Thursdays 8:00-5:30.

If attempts to reach the examiner by telephone are unsuccessful, examiner's supervisor, William B. Baumeister, can be reached on (571) 272-1722. The fax phone numbers for the organization where this application or processing is assigned is (703) 873-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published application may be obtained from either Private PAIR or Public PAIR. Status information for unpublished application is available through Private PAIR only. For more information

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about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Victor Yevsikov

Examiner Art Unit 2891

April 1, 2006

Assle Union Sartiar 4/3/06

ASOK K. SARKAR PRIMARY EXAMINER